

DIGITAL CIRCUITS

Exam TSEI03

Time: Monday 21 October 2019, 14:00–18:00

Place: U4

Teacher: Mark Vesterbacka, phone 013-281324

Allowed aid: Calculator

Max score: 60 points

Grades:
45 points for 5
35 points for 4
25 points for 3

Solutions: Posted on the course web

Result: Posted through LADOK by Wednesday 6 November 2019

- 1 a) What is the maximal value on the *gate capacitance* of a MOSFET? (2 p)
- b) What is the *voltage transfer characteristic* (VTC) of a digital circuit? (2 p)
- c) Explain how the *resistance of a conducting transmission gate* can be designed to be approximately constant. (2 p)
- 2 Given the data in Figure 1 for a short channel NMOS transistor with $V_{DSAT} = 0.58$ V and $k' = 122 \mu\text{A}/\text{V}^2$, calculate the parameters below.
- | | | Data set | V_{GS} (V) | V_{DS} (V) | V_{BS} (V) | I_D (μA) |
|----|-------------|----------|--------------|--------------|--------------|-------------------------|
| a) | V_{T0} | 1 | 2.5 | 1.8 | 0 | 1812 |
| b) | γ | 2 | 2 | 1.8 | 0 | 1297 |
| c) | $2 \phi_F $ | 3 | 2 | 2.5 | 0 | 1361 |
| b) | W/L | 4 | 2 | 1.8 | -1 | 1146 |
| | | 5 | 2 | 1.8 | -2 | 1039 |
- Figure 1. Measured NMOS transistor data.
- 3 A metal wire have resistance $R_{wire} = 2 \Omega$, sheet resistance $R_{sq} = 0.07 \Omega/\text{square}$, width $W_{wire} = 3 \mu\text{m}$, capacitance per area $C_{area} = 0.019 \text{ fF}/\mu\text{m}^2$, and capacitance per length $C_{edge} = 0.025 \text{ fF}/\mu\text{m}$.
- a) Why is sheet resistance measured in Ω/square ? (2 p)
- b) Calculate the length of the wire. (4 p)
- c) Calculate the total capacitance of the wire. (4 p)
- 4 The function $F = AB + \overline{CD}$ shall be implemented. Complements to the inputs are *not* available.
- a) Implement the function with a static CMOS gate and static CMOS inverters. (5 p)
- b) Size all transistors so that the worst-case output resistance of the gate and inverters is the same as that of an inverter with an NMOS $W/L = 3$ and PMOS $W/L = 5$. (5 p)

- 5 A precharged 2-input NAND gate shall be designed.
- Draw the transistor schematic of the gate. (4 p)
 - Explain the operation of the gate. (4 p)
 - Explain how charge sharing may occur. (4 p)
- 6 A negative edge-triggered master-slave D flip-flop shall be designed.
- Use inverters and transmission gates to design a D flip-flop that transfers the logical value at the input D to the output Q when the clock falls from high to low. (5 p)
 - Sketch a timing diagram that illustrates the transfer of both a low and a high logical value from D to Q . Include the clock, input, and output nodes, as well as the intermediate node between the two latches. Define the *setup time*, *hold time* and *clock-to-output delays* (high-to-low and low-to-high). What can happen if the setup time or hold time is violated? (5 p)

Equations for the MOS transistor



Definition of source (S) and drain (D)

NMOS: $V_S \leq V_D$ PMOS: $V_S \geq V_D$

Voltage notations

$$V_{GS} = V_G - V_S, V_{DS} = V_D - V_S, V_{SB} = V_S - V_B, V_{GT} = V_{GS} - V_T$$

Threshold voltage

$$V_T = V_{T0} + \gamma(\sqrt{|V_{SB} - 2\Phi_F|} - \sqrt{2|\Phi_F|})$$

Unified model

NMOS: $V_{GT} \leq 0$ (PMOS: $V_{GT} \geq 0$) \Rightarrow Subthreshold region ($I_D \approx 0$)

$$\text{NMOS: } V_{GT} \geq 0 \text{ (PMOS: } V_{GT} \leq 0) \Rightarrow I_D = k' \frac{W}{L} V_{min} \left(|V_{GT}| - \frac{V_{min}}{2} \right) (1 + \lambda V_{DS})$$

$$V_{min} = \min(|V_{GT}|, |V_{DS}|, |V_{DSAT}|)$$

$$V_{min} = |V_{GT}| \Rightarrow \text{saturation region}$$

$V_{min} = |V_{DS}| \Rightarrow$ resistive (linear, triode) region ($\lambda = 0$)

$V_{min} = |V_{DSAT}| \Rightarrow$ velocity saturation region

V_{DSAT} dependency on channel length

$$V_{DSAT} = L \xi_c$$

Subthreshold region

$$\text{NMOS: } V_{GT} \leq 0 \Rightarrow I_{Dn} = I_{Dn} \frac{W}{L} e^{\frac{q(V_{GSn} - V_{Tn})}{nkT}} \left(1 - e^{-\frac{qV_{DSn}}{kT}} \right) (1 + \lambda_n V_{DSn})$$

$$\text{PMOS: } V_{GT} \geq 0 \Rightarrow I_{Dp} = I_{Dp} \frac{W}{L} e^{\frac{q(V_{SGp} - |V_{Tp}|)}{nkT}} \left(1 - e^{-\frac{qV_{SDp}}{kT}} \right) (1 + \lambda_p V_{DSp})$$

Model parameters for 0.25 μm CMOS devices

Parameters for drain current calculations

	G	$I_D \frac{Q}{L}$	S	B
NMOS				
PMOS				

Parameters for capacitance calculations

	C_{ox} [fF/μm ²]	C_O [fF/μm]	C_j [fF/μm ²]	m_j	ϕ_b [V]	C_{jsw} [fF/μm]	m_{jsw}	$\phi_{b_{sw}}$ [V]
NMOS	6	0.31	2.0	0.50	0.9	0.28	0.44	0.9
PMOS	6	0.27	1.9	0.48	0.9	0.22	0.32	0.9

Gate capacitance

Overlap capacitance

$$C_{GSO} = C_{GDO} = C_{ox} x_d W = C_o W$$

Channel capacitance

$$C_{GC} = C_{GCB} + C_{GCS} + C_{GCD}$$

Condition	C_{GCB}	C_{GCS}	C_{GCD}
$V_{GTn} \leq 0, V_{GTP} \geq 0$	$C_{ox} WL$	0	0
$V_{GTn} > 0, V_{GTP} < 0, V_{DS} \leq V_{GT} $	0	$C_{ox} WL/2$	$C_{ox} WL/2$
$V_{GTn} > 0, V_{GTP} < 0, V_{GT} \leq V_{DS} $	0	$2C_{ox} WL/3$	0

Junction capacitance

Junction capacitance as function of voltage

$$C_j(V) = \frac{C_{j0}}{(1 - V/\phi_0)^m}$$

Average capacitance during transition from V_1 to V_2

$$C_{eq} = K_{eq} C_{j0} = \frac{-\phi_0^m}{(V_2 - V_1)(1-m)} [(\phi_0 - V_2)^{(1-m)} - (\phi_0 - V_1)^{(1-m)}] C_{j0}$$

Dynamic power consumption

$$P = \alpha f C_{tot} V_{dd}^2$$

Switch functions

$$S_N = \overline{F(A, B, \dots)}, S_P = F(\bar{A}, \bar{B}, \dots)$$

Boolean algebra

De Morgans' theorem

$$\overline{X + Y + Z + \dots} = \overline{\bar{X}\bar{Y}\bar{Z}\dots}, \quad \overline{XYZ\dots} = \bar{X} + \bar{Y} + \bar{Z} + \dots$$

Expansion in sum

$$f(X, Y, Z, \dots) = Xf(1, Y, Z, \dots) + \bar{X}f(0, Y, Z, \dots)$$

Expansion in product

$$f(X, Y, Z, \dots) = [X + f(0, Y, Z, \dots)][\bar{X} + f(1, Y, Z, \dots)]$$

Transmission line

Characteristic impedance

$$Z_0 = \sqrt{L/C}$$

Velocity of wave

$$v = 1/\sqrt{LC}$$

Reflection coefficient for a transmission line (Z_0) terminated by a load (Z_L)

$$\Gamma = (Z_L - Z_0)/(Z_L + Z_0)$$

Elmore delay

P_i = “the path between node 0 and i ”.

$P_{ij} = P_i \cap P_j$ = “the common part of the paths P_i and P_j ”.

R_{ij} = “the sum of all resistances in P_{ij} ”.

Time constant from node 0 to i : $\tau_{di} = \sum_{j=0}^n R_{ij} C_j$. Propagation delay: $t_{pi} \approx 0.69 \tau_{di}$.

Sizing of cascaded inverters

For minimal propagation delay find the best solution to $1 = e^{(1+\gamma/k)/k}$, where k = “tapering factor”, N = “number of inverters”, $F = C_L/C_{g1} = k^N$ and $\gamma = C_{int1}/C_{g1}$.